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SELECTIVE DEPROTECTION OF ALCOHOLIC AND PHENOLIC SILYL ETHERS

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ABSTRACT : Hydrofluoric acid and tetrsbutylammoniun fluoride will selectively deprotect alcoholic and phenolic silyl ethers respectively.

One of the most common hydroxyl protecting functions presently in use is the t-butyldimethylsilyl moiety^l. This group is easy to introduce² and of a variety of reagents³ that exist for its removal the most useful is tetrabutylammonium fluoride. More recently⁴ it has been suggested that the use of aqueous hydrofluoric acid is complementary; specifically it allows the removal of the silyl groups from the highly sensitive PGD₂ precursor (1).

We have discovered that these fluorine containing reagents can be used to effect selective desilylation of compounds containing both phenolic and alcoholic t-butyldimethylsilyl ethers. Thus, under carefully controlled conditions, aqueous hydrofluoric acid in acetonitrile selectively regenerates the alcohol function whereas tetrabutylsmmoniun fluoride in tetrahydrofuran liberates the corresponding phenol **(Scheme 1). As expected the use of an excess of** either reagent eventually results in complete deprotection.

Generally both reactions proceed very cleanly although the deprotections with hydrofluoric acid give reduced yields when the substrates are acid sensitive (Table, entries 4 and 7) or the masked hydroxyl group is sterically hindered (entry 9). In some instances reduced yields were also observed with the fluoride ion-mediated desilylations because concomitant removal of the alcoholic silyl moiety also occurred (entries 3 and 8). However, the use of short contact times (1-2 mins.) and toluene as solvent circumvented these problems and significantly improved the amount of desired product.

Interestingly, both types of products were isolated when the saligenin derivative (entry 3) was treated with tetrabutylammonium fluoride in toluene. This is rationalised on the basis of a fluoride ion-assisted silyl group migration 5 (Scheme 2) rather than a non-selective deprotection process. This postulate is supported by the observation that where intramolecular silyl migration is not possible (entry 2) then no deprotection of the alcoholic silyl moiety occurs.

Scheme 2

The selective deprotection is also successful with the t-butyldiphenylsilyl group⁶ although more drastic conditions are required to liberate the free **alcohol function (Scheme 3).** Similar attempts with the trimethyIsily1 moiety failed and only fully deprotected compounds were recovered.

Conditions A

2 equivalents of 40% aqueous HF are added to a solution of the substrate in **MeCN** at either 0^0 or room temperature. When the reaction is complete by $t.l.c.$ analysis (\sim 30 mins.) an excess of 8% NaHCO $_3$ is added and the product is extracted into ether. Purification is carried out by flash chromatography $^\prime$ on silica gel.

Conditions El

1 equivalent of 1M Bu₄NF/THF is added to a solution of the substrate in THF at 0^0 . After \sim 15 mins. an excess of aqueous NH₄C1 is added and the product isolated as in A.

a. Evidence for olefin containing by-produc

b. Complete deprotection to the corresponding diol waa observed with leq Bu,NF.

38% Yield of product B waa obtained with 0.5eq Bu,,NF.

c. Toluene/0°/2 mina. Amount of product A increasea with increased reaction time.

d. 50% Yield of corresponding diol also produced. e **. Toluene/0'/2 mina.**

Table

REFERENCES

- **1. E. W. Colvin, Chem. Sot. Rev., 1978, 1, 35.**
- **2. E. J. Corey and A. Venkateswarlu, J. Am. Chem. Sot., 1972, 94, 6190.**
- **3. T. V. Lee, S. M. Roberts, M. J. Dimsdsle, R. F. Newton, D. K. Rsiney and C. F. Webb, J. Chem. Sot. Perkin Trans. 1, 1978, 1176.**
	- **D. R. Kelly, S. M. Roberts and R. F. Newton, Synth. Commun., 1979, 2, 295.**
- **4. R. F. Newton, D. P. Reynolds, M. A. W. Finch, D. R. Kelly and S. M. Roberts, Tetrahedron Lett., 1979, 3981. R. F. Newton, D. P. Reynolds, C. F. Webb and S. M. Roberts,**
	- **J. Chem. Sot. Perkin Trans. 1, 1981, 2055.**
- **5. Other examples of similar silyl group migrations hsve been reported. Y. Torisawa, M. Shibasski and S. Ikegami, Tetrahedron Lett., 1979, 1865. C. Howard. R. F. Newton, D. P. Reynolds end S. M. Roberts,** J. Chem. Soc. Perkin Trans. 1, 1981, 204**9.**
W. Kohler and W. Pfleiderer, Abstract Papers Am. Chem. Soc. 1976, 172, **CARB61.**
- 6. **5. Hanessian and P. Lavallee, Can. J. Chem., 1975, 3, 2975.**
- **7. W. C. Still, M. Kahn and A. Mitra, J. Org. Chem., 1978, 43, 2923.**
- **8. The silyl ethers** *were* **prepared by conventional methods** (ref. yields of 75–99%. All new compounds possessed satisfactory spectroscopic and **2) and were obtained** in **analytics1 data.**
- **9. Substrates** for entries 5-7 were prepared as follows:-

a. KF/A1z03; 89% b. Hz/Pd; 95% $R = {}^tB$ uMe₂ Si **c. RCl/DMF/Imidazole; 83%**

10. H. 0. House and H. Badad, J. Org. Chem., 1963, 28, 90. **(Received in** UK 19 November 1984)